# UTILITY PATENT APPLICATION TRANSMITTAL for new nonprovisional applications under 37 CFR 1 53,b-1

Attorney Docket No.

209291US0

First Inventor or Application Identifier

Hiroyuki NAGAŞ

et al.

METHOD OF MANUFACTURING SILICO ARBIDE, SILICON CARBIDE, COMPOSITE MATERIAL, AND SEMICONDUCTOR ELEMENT

Assignee Name HOYA CORPORATION

Assignee Address

7-5, Naka-Ochiai 2-chome, Shinjuku-ku, Tokyo 161-0032, Japan

APPLICATION ELEMENTS See MPEP chapter 600 concerning utility patent application contents	Assistant Commissioner for Patents Box Patent Application Washington, DC 20231			
Fee Transmittal Form (e.g. PTO/SB/17)     (Submit an original and a duplicate for fee processing)	ACCOMPANYING APPLICATION PARTS			
	7.   Assignment Papers (cover sheet & document(s))			
2. ■ Specification Total Sheets 36	8. ■ Application Data Sheet. See 37 CFR 1.76			
	9.   37 C.F.R. §3.73(b) Statement   Power of Attorney			
3. ■ Drawing(s) (35 U.S.C. 113) Total Sheets (Formals)	10. □ English Translation Document (if applicable)			
	11.  Information Disclosure Statement (IDS)/PTO-1449 Copies of IDS Citations			
4. □ Oath or Declaration Total Pages	12.   □ Preliminary Amendment			
a. □ Newly executed (original or copy)	13. ■ White Advance Serial No. Postcard			
b.  Copy from a prior application (37 C.F.R, §1.63(d)) (for continuation / divisional w/ box 17 completed)	14. ■ Certified Copy of Priority Document(s) (1)			
<ul> <li>DELETION OF INVENTOR(S)         Signed statement attached deleting inventor(s) named in the prior application, see 37 C.F.R. §1.63(d)(2) and 1.33(b).     </li> </ul>	15. □ Applicant claims small entity status. See 37 CFR 1.27			
5. ☐ CD-ROM or CD-R in duplicate, large table or Computer Program ( <i>Appendix</i> )	16. ■ Other: Notice of Priority, List of Inventors' Names and Addresses			
6. ☐ Nucleotide and/or Amino Acid Sequence Submission (if applicable, all necessary)				
a.   Computer Readable Form (CRF)				
b. Specification or Sequence Listing on:				
i. ☐ CD-ROM or CD-R (2 copies); or				
ii. □ Paper				
c.   Statements verifying identity of above copies				
17. If a CONTINUING APPLICATION, check appropriate box, and sup.  Continuation  Divisional  Continuation-  Prior application information:  Examiner:  For CONTINUATION OR DIVISIONAL APPS only: The entire disclosure of the pricconsidered a part of the accompanying continuation or divisional application and is when a portion has been inadvertently omitted from the submitted application parts	of prior application no.  Group Art Unit			
18. Amend the specification by inserting before the first line the se	entence:			
☐ This application is a ☐ Continuation ☐ Division of application Serial No. ☐ Filed on ☐ Which was published in English	□ Continuation-in-part (CIP)			
<ul><li>Which was published in English</li><li>Which was not published in English</li></ul>				
☐ This application claims priority of provisional application Seria	l No. Filed			
This application claims priority of provisional application dena	THEU			
19. CORRESPONDENCE ADDRESS				
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Name:	Norman F. Oblon	Registration No.:	24,618
Signature:	6 mm Maylan	Date:	5/3//01
Name:	,	Registration No.:	

Docket No.

209291US0

# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INVENTOR(S) Hirovuki NAGASAWA, et al.

SERIAL NO:

New Application

FILING DATE: Herewith

FOR:

METHOD OF MANUFACTURING SILICON CARBIDE, SILICON CARBIDE, COMPOSITE MATERIAL,

AND SEMICONDUCTOR ELEMENT

### FEE TRANSMITTAL

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

FOR	NUMBER FILED	NUMBER EXTRA	RATE	CALCULATIONS
TOTAL CLAIMS	13 - 20 =	0	× \$18 =	\$0.00
INDEPENDENT CLAIMS	2 - 3 =	()	× \$80 =	\$0.00
■ MULTIPLE DEPENDENT CLAIMS (If applicable) + \$270 =				\$270.00
■ LATE FILING OF DECLARATION + \$130 =				\$130.00
	\$710.00			
TOTAL OF ABOVE CALCULATIONS				\$1,110.00
□ REDUCTION BY 50% I	\$0.00			
□ FILING IN NON-ENGLISH LANGUAGE		+ \$130 =	\$0.00	
□ RECORDATION OF AS	SSIGNMENT		+ \$40 =	\$0.00
			TOTAL	\$1,110.00

Please charge Deposit Account No. 15-0030 in the amount of

A duplicate copy of this sheet is enclosed.

- A check in the amount of
- \$1,110.00
- to cover the filing fee is enclosed.

The Commissioner is hereby authorized to charge any additional fees which may be required for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

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24,618

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IN RE APPLICATION OF: Hiroyuki NAGASAWA, et al.

FILING DATE: Herewith

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AND SEMICONDUCTOR ELEMENT

## LIST OF INVENTORS' NAMES AND ADDRESSES

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

Listed below are the names and addresses of the inventors for the above-identified patent application.

Hiroyuki NAGASAWA

Tokyo, Japan

Takamitsu KAWAHARA

Kawasaki-shi, Japan

Kuniaki YAGI

Tokyo, Japan

A declaration containing all the necessary information will be submitted at a later date.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

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